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## N THE UNITED STATES PATENT & TRADEMARK OFFICE

Applicant:

Pocker et al.

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Examiner: Stevan A. Resan

Title: "ENERGY GRADIENT ION BEAM DEPOSITION OF CARBON OVERCOATS

ON RIGID D. SK MEDIA FOR MAGNETIC RECORDINGS"

Box Non Fee Amundment Commissioner for Patents Washington, D.C. 20231

## SUBSTITUTE PRELIMINARY AMENDMENT

Sir:

Applicant submits this Substitute Preliminary Amendment in response to a Notice of Non-Compliant Amendment mailed November 8, 2002, to replace the Preliminary Amendment filed concurrent with Applicant's Response to the Restriction Requirement.

## In the Abstract

Please replace the original Abstract with the Abstract set forth below. A marked-up copy of the Abstract is submitted herewith as Attachment B.

The fabrication of an overcoat layer starts with a low energy ion beam to avoid magnetic layer implantation problems, followed by higher deposition energies where the higher energy atoms are implanted into the previously formed lower energy overcoat layer, rather than the magnetic layer. The energy gradient ion beam deposition process therefore results in a thin overcoat layer that is denser than a comparable layer formed by low energy magnetron sputtering, and which overcoat layer provides good mechanical and corrosion protection to the magnetic layer.